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Sheet	1	of	1	Application Number	TBD
				Filing Date	Herewith
				First Named Inventor	William W. Dostalik
				Group Art Unit	2814
				Examiner Name	Howard Weiss
				Attorney Docket No.	TI-34962.1

U.S. PATENT DOCUMENTS						
Exam. Initials*	Cite No. <sup>1</sup>	U.S. Patent Document		Name of Patentee or Applicant of Cited Doc.	Date of Pub. of Cited Doc. (mm-dd-yyyy)	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number	Kind Code <sup>2</sup> (if known)			
PC	AA	6,319,809		Chang et al.	11/20/01	
PC	AB	8,372,647		Lu et al.	4/16/02	
	AC					
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FOREIGN PATENT DOCUMENTS							
Exam. Initials*	Cite No. <sup>1</sup>	Foreign Patent Document		Name of Patentee or Applicant of Cited Doc.	Date of Pub. of Cited Doc. (mm-dd-yyyy)	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T <sup>3</sup>
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OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS						
Exam. Initials*	Cite No. <sup>1</sup>	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.				T <sup>2</sup>
PC	CA	U.S. Patent Application Publication No. 2002/0081855, June 27, 200, Jiang et al.				
PC	CB	S. SATYANARAYANA ET AL., "A Solution to Resist Poisoning in the Integration of 248 and 193 nm Photoresist with Low-k Dielectric Materials" Society of Photo-Optical Instrumentation Engineers, Santa Clara, California, March 2002				
	CC					
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Examiner Signature	PHAT X. CAO	Date Considered	9/1/05
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\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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